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10/661,736

25859

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1650 MEMOREX DRIVE SANTA CLARA, CA 95050

FOXCONN INTERNATIONAL, INC.

WEI TE CHUNG

01/07/2005

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FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
Chuan De Lai		8296
	EXAMINER	
	KIM, RICHARD H	

2871

ART UNIT

DATE MAILED: 01/07/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

		Application No.	Applicant(s)		
		10/661,736	LAI, CHUAN DE		
	Office Action Summary	Examiner	Art Unit		
	Richard H Kim	2871			
The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply					
THE - Exte after - If the - If NC - Failu Any	ORTENED STATUTORY PERIOD FOR REPL'MAILING DATE OF THIS COMMUNICATION. nsions of time may be available under the provisions of 37 CFR 1.1 SIX (6) MONTHS from the mailing date of this communication. period for reply specified above is less than thirty (30) days, a reply period for reply is specified above, the maximum statutory period or re to reply within the set or extended period for reply will, by statute reply received by the Office later than three months after the mailing ed patent term adjustment. See 37 CFR 1.704(b).	36(a). In no event, however, may a reply be timy within the statutory minimum of thirty (30) days will apply and will expire SIX (6) MONTHS from , cause the application to become ABANDONE	nely filed s will be considered timely. the mailing date of this communication. D (35 U.S.C. § 133).		
Status			•		
1)□	Responsive to communication(s) filed on				
2a) <u></u> ☐	This action is FINAL . 2b)⊠ This	action is non-final.			
3)[3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.				
Dispositi	on of Claims				
4) Claim(s) 1-14 is/are pending in the application. 4a) Of the above claim(s) is/are withdrawn from consideration. 5) Claim(s) is/are allowed. 6) Claim(s) 1-14 is/are rejected. 7) Claim(s) is/are objected to. 8) Claim(s) are subject to restriction and/or election requirement.					
Applicati	on Papers				
 9) ☐ The specification is objected to by the Examiner. 10) ☑ The drawing(s) filed on 11 September 2003 is/are: a) ☑ accepted or b) ☐ objected to by the Examiner. Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a). Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d). 11) ☐ The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152. 					
Priority u	ınder 35 U.S.C. § 119				
12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received.					
Attachmen	t(s)				
	e of References Cited (PTO-892)	4) Interview Summary (
3) 🛛 Inform	e of Draftsperson's Patent Drawing Review (PTO-948) nation Disclosure Statement(s) (PTO-1449 or PTO/SB/08) No(s)/Mail Date 9/11/03.	Paper No(s)/Mail Da 5) Notice of Informal Pa 6) Other:	te atent Application (PTO-152)		

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DETAILED ACTION

Claim Rejections - 35 USC § 102

1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

2. Claims 10-12 rejected under 35 U.S.C. 102(b) as being anticipated by Yamushita (US 6,309,079 B1).

Referring to claim 10, Yamishita discloses a backlight system comprising a light guide plate defining a plurality of side faces and opposite bottom and exit faces (Fig. 10, ref. 101), the side face commonly defining a periphery of the light guide plate (101); and a plurality of point light sources essentially uniformly dispersed along the periphery and commonly directed toward a center region of the light guide plate (Fig. 13, ref. 102).

Referring to claim 11, Yamashita discloses that the point light sources are located at corner of the light guide plate (Fig. 13, ref. 102, 101).

Referring to claim 12, Yamashita discloses that an incident face is formed at each of the corners (Fig. 13, ref. 101).

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Claim Rejections - 35 USC § 103

- 1. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 2. Claims 1-9 are rejected under 35 U.S.C. 103(a) as being unpatentable over Yamushita (US 6,309,079 B1) in view of Akahane (US 5,931,555).

Referring to claims 1, 4 and 7, Yamushita discloses a device comprising a light guide plate including a plurality of incident surfaces disposed at the corners thereof (Fig. 13, ref. 101); a light exit surface and a bottom surface opposite to the light exit surface (Fig. 12); and a plurality of point light sources for emitting light beams disposed adjacent and opposite to the incident surface (Fig. 13, ref. 102). However, the reference does not disclose that the bottom surface has a plurality of rectangular dots thereon, and a covering rate of the scattering pattern varies such that a light distribution density of light emitted from the light guide plate is uniform.

Akahane discloses a device wherein the bottom surface comprises a light scattering pattern having a plurality of rectangular dots thereon, and a covering rate of the scattering pattern varies such that a light distribution density of light emitted from the light guide plate is uniform (Fig. 9).

It would have been obvious to one having ordinary skill in the art at the time the invention was made to employ a light scattering pattern having a plurality of dots thereon, and a covering rate of the scattering pattern varies such that a light distribution density of light emitted

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from the light guide plate is uniform since one would be motivated to improve the uniformity of luminance (abstract).

Referring to claim 2, Yamishita and Akahane disclose the device previously recited, but fails to disclose that the point light sources are light emitting diodes.

It would have been obvious to one having ordinary skill in the art at the time the invention was made for the point light sources to be light emitting diodes since light emitting diodes are well known in the art to be a strong and reliable light source.

Referring to claims 3 and 8, Yamashita further discloses four incident surfaces disposed at opposite corners thereof (Fig. 3, ref. 101).

Referring to claims 5 and 9, Yamashita further discloses that the bottom surface further comprises a reflective film (Fig. 10, ref. 103).

Referring to claim 6, Yamashita and Akahane disclose the device previously recited, but fails to disclose that the reflective ratio is greater than 98% for wavelengths in the range of the visible spectrum.

It would have been obvious to one having ordinary skill in the art at the time the invention was made for the reflective ratio to be greater than 98% for wavelengths in the range of the visible spectrum since an skilled artisan in the art would have known that improving the reflectivity of the reflective film would improve the brightness of the display. Therefore, limiting the reflective film to have a reflectivity of 98% or greater would have been obvious in order to improve display brightness.

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3. Claims 13 and 14 are rejected under 35 U.S.C. 103(a) as being unpatentable over Yamashita.

Yamashita discloses the device previously recited, but fails to disclose that each of the point light sources defines an effective angle range between two lines, and one of the two lines is aligned with one corresponding face, wherein each of the point light sources has two neighboring light sources, and at least one of the two neighboring point light sources defines another effective angle range between another two lines wherein one of the another two lines is aligned with the same one corresponding side face so that an area beside the one corresponding side face belongs to a higher light intensity distribution area.

It would have been obvious to one having ordinary skill in the art at the time the invention was made for each of the point light sources to define an effective angle range between two lines, and one of the two lines is aligned with one corresponding face, wherein each of the point light sources has two neighboring light sources, and at least one of the two neighboring point light sources defines another effective angle range between another two lines wherein one of the another two lines is aligned with the same one corresponding side face so that an area beside the one corresponding side face belongs to a higher light intensity distribution area since optimally arranging the point light sources in order to achieve improved light uniformity and brightness requires only routine skill in the art.

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Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Richard H Kim whose telephone number is (571)272-2294. The examiner can normally be reached on 9:00-6:30 M-F.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Robert H Kim can be reached on (571)272-2293. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Richard H Kim Examiner Art Unit 2871

RHK

TARIFUR R. CHOWDHURY
PRIMARY EXAMINER